

HIGH-EFFICIENCY SOLAR CELLS

**N 8 7 - 1 6 4 1 5**

**MEASUREMENT OF MINORITY CARRIER LIFETIME,  
MOBILITY AND DIFFUSION LENGTH IN HEAVILY  
DOPED SILICON**

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Outline

Introduction

Measurement of Minority Carrier Lifetimes in  $p^+$  and  $n^+$  Si

- photoluminescence decay technique
- data reduction
- fits of lifetime vs. doping data ( $p^+$  and  $n^+$ )

Measurement of Diffusion Length and Mobility in  $p^+$  and  $n^+$  Si

- lateral transistor test structure
- typical diffusion length data
- diffusion length vs. doping in  $p^+$  Si
- electron (minority carrier) mobility vs. doping
- hole (minority carrier) mobility vs. doping

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### Minority Carrier Lifetime in $n^+$ and $p^+$ Silicon Recombination Paths

- Shockley-Read-Hall Recombination

$$\tau_p = (N_t v \sigma)^{-1}$$

– lifetime independent of doping, dependent on  $N_t$

- Auger Recombination: Trap Assisted

$$\tau_p = (T_n n N_t)^{-1}$$

– lifetime dependent on doping,  $N_t$

- Auger Recombination: Band to Band

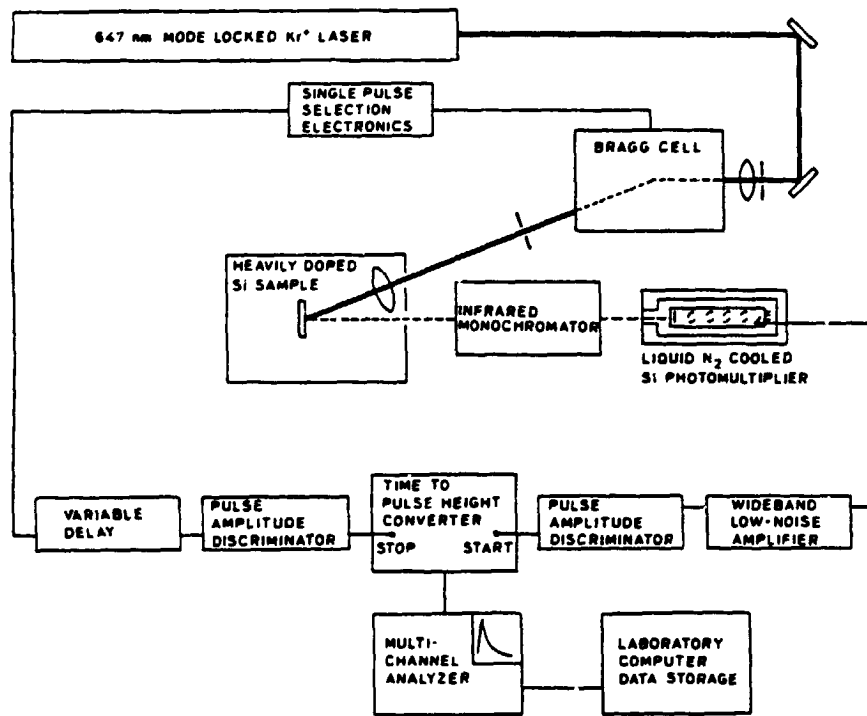
$$\tau_p = (C_n n^2)^{-1}$$

– lifetime dependent on doping only

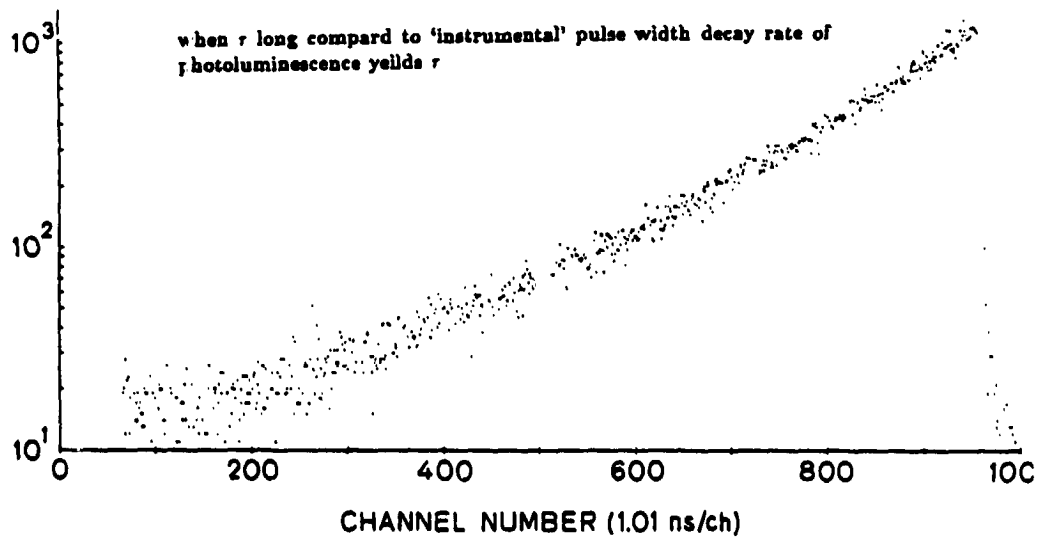
### Photoluminescence Lifetime Decay

- short (200 ps) laser pulse generates minority carriers
- monitor decay of luminescence radiation

Photoluminescence Decay Lifetime Measurement Apparatus



Photoluminescence Decay  
 Si:Sb  $4.2 \cdot 10^{18}$   
 $\tau = 160 \text{ ns} \pm 10\%$

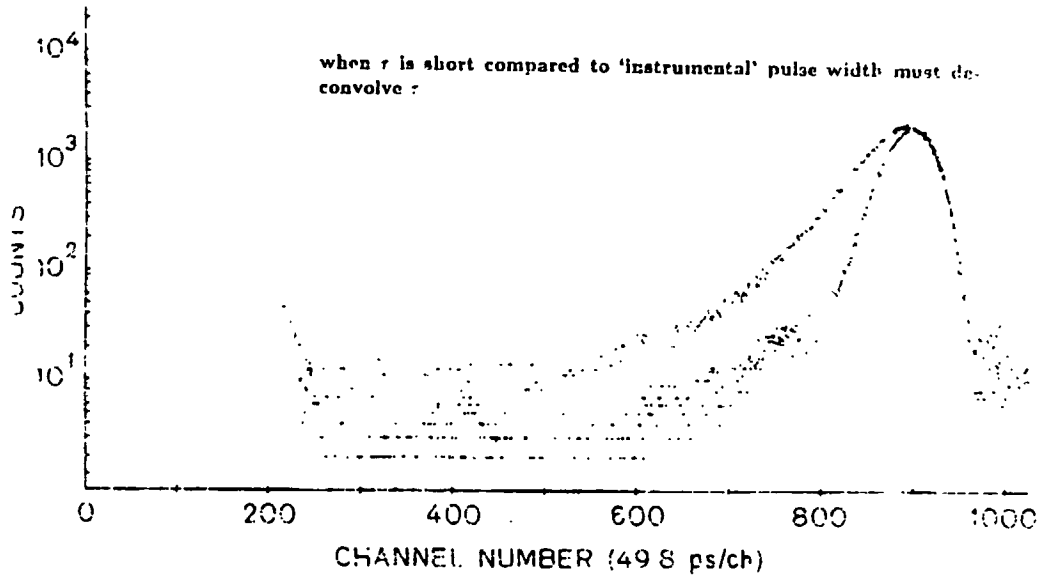


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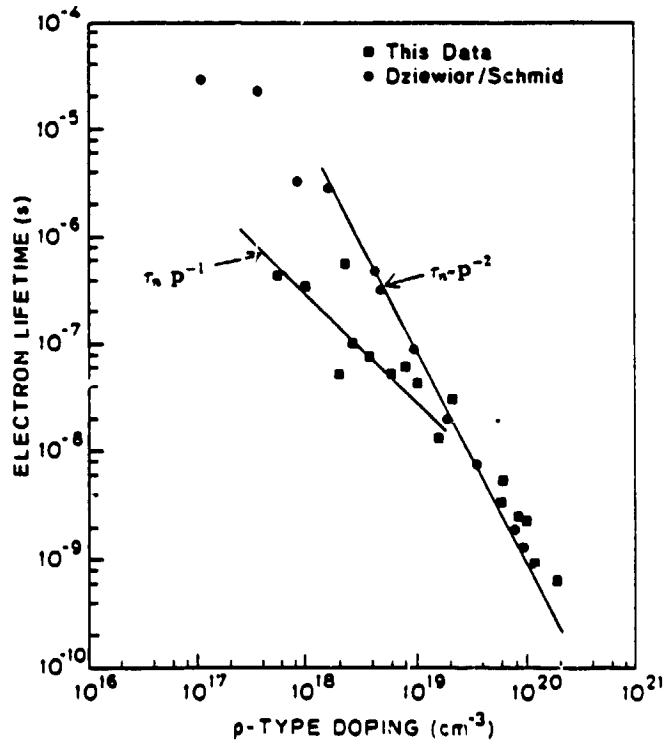
## Photoluminescence Decay

Si:Ph  $9.2 \cdot 10^{19}$

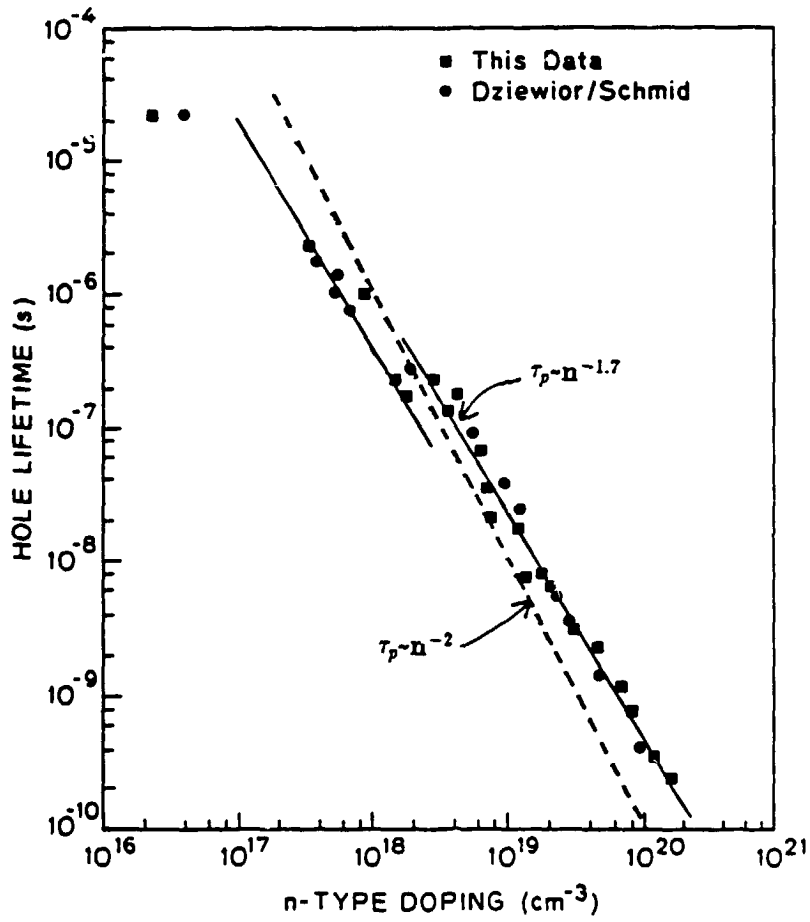
$\tau = 880 \text{ ps} \pm 20\%$



## Electron Lifetime in p-Type Silicon



Hole Lifetime in n-Type Silicon

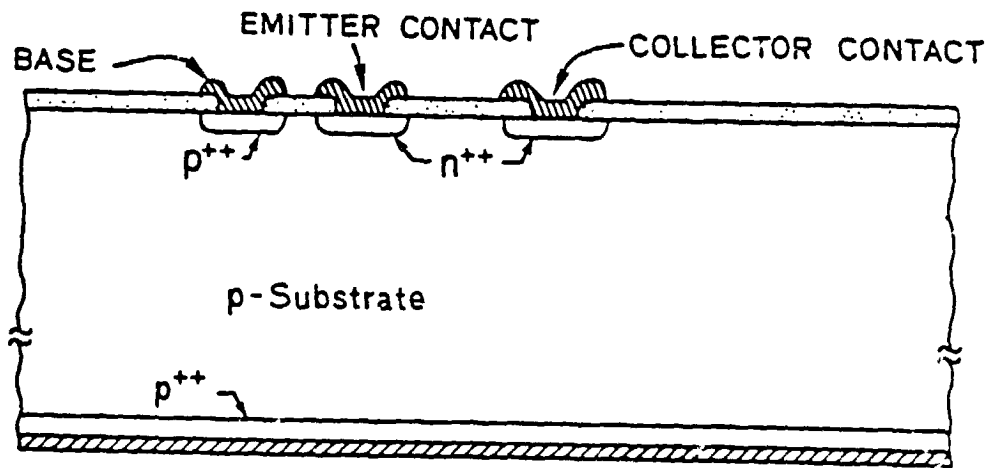


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### Measurement of Diffusion Length and Mobility

- Diffusion Length (electrons in  $p^+$  Si)  $L_n = \sqrt{D_n \tau_n}$
- Mobility (electrons in  $p^+$  Si)  $\mu_n = q/kT D_n$

#### Lateral Transistor to Measure $L_n$

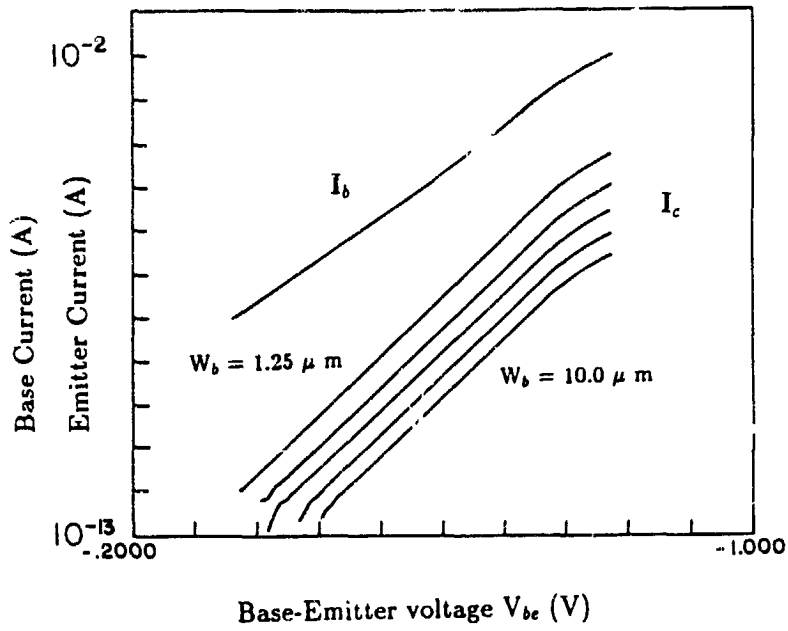


$$I_c = I_{c0} (e^{(qV_{be}/kT)} - 1)$$

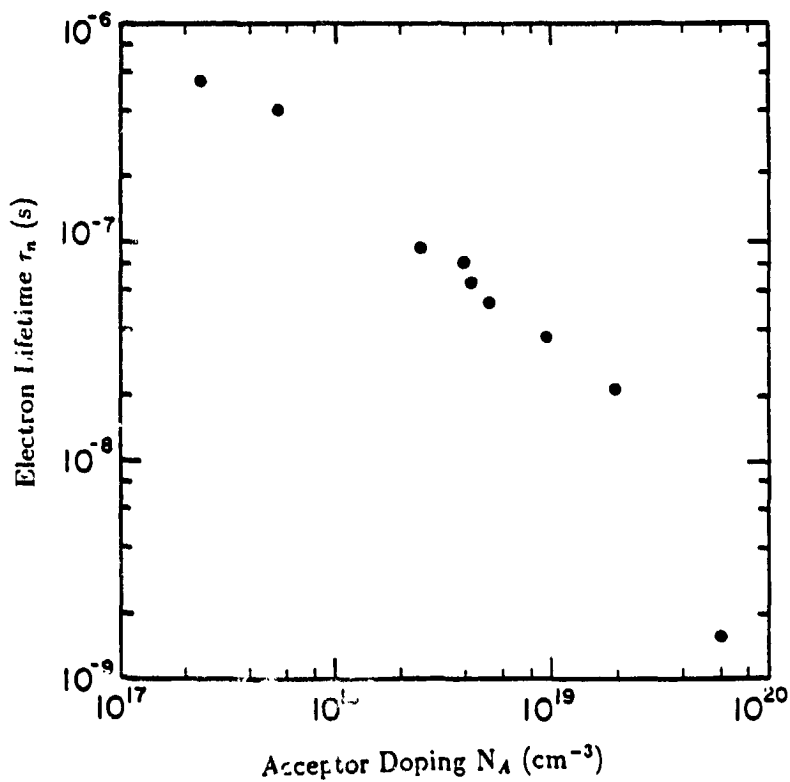
$$I_{c0} = \frac{qAn_0D_n}{L_n} e^{-(W_b/L_n)} \quad \text{when } W_b \gg L_n$$

use similar structures with varying  $W_b$  to obtain  $L_n$

Gummel Plot of Lateral Bipolar Transistors

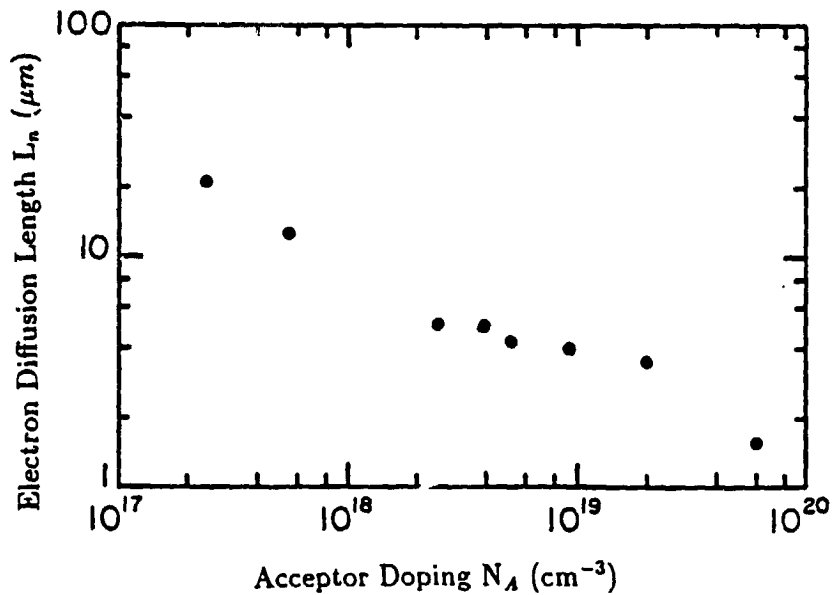


Electron Lifetimes of  $L_n$  Samples

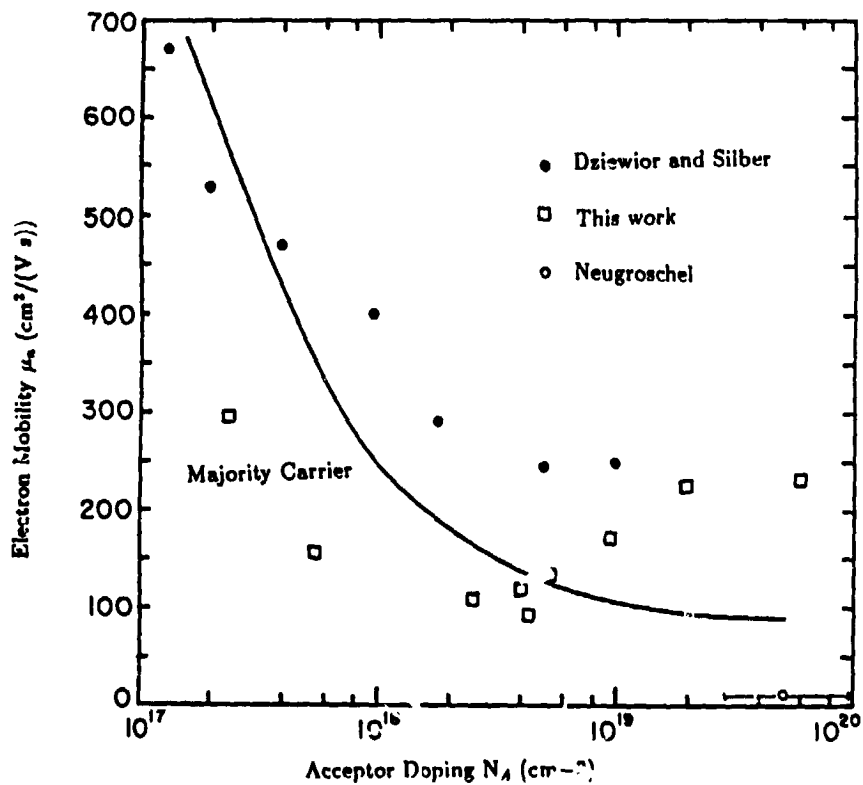


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## Extracted Electron Diffusion Lengths



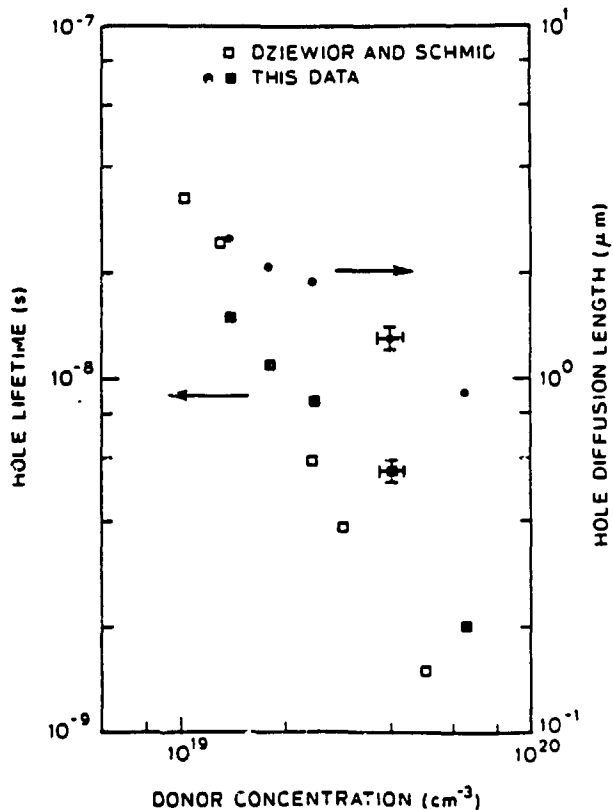
## Electron Mobility at 300°K



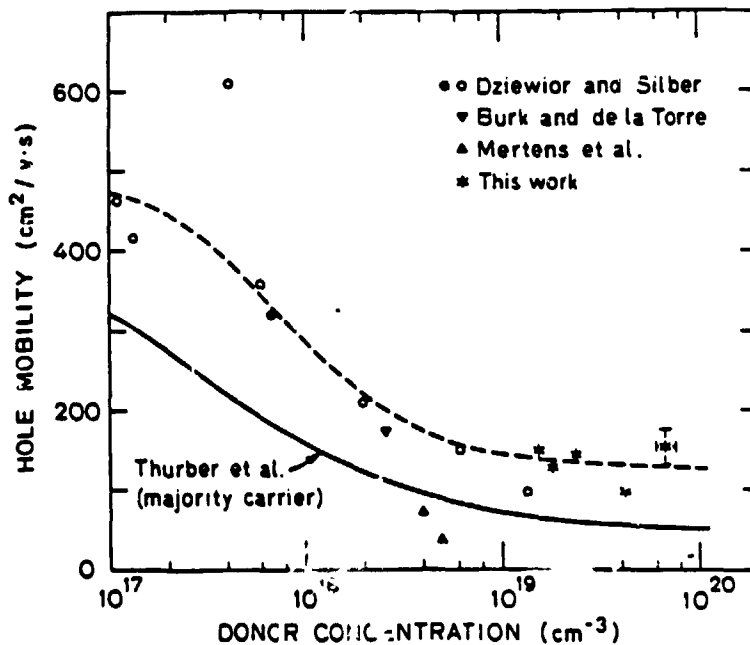


# HIGH-EFFICIENCY SOLAR CELLS

## $L_p$ and $\tau_p$ in Heavily Doped Epitaxial Silicon



## Hole Mobility in P epi Silicon



## Conclusions

### Lifetime in heavily doped Si

- first comprehensive measurements of  $\tau_n, \tau_p$  in processed heavily doped Si
- $\tau$  measurements extended into  $10^{20} \text{ cm}^{-3}$  doping range
- photoluminescence decay technique suitable and accurate
- $\tau_n$  in  $p^+$  Si
  - 'standard'  $\tau_n$  dependence with  $N_A^{-2}$  accurate in very limited range
  - lifetime modeled best by sum of inverse plus inverse square dependence on  $N_A$
- $\tau_p$  in  $n^+$  Si
  - previously observed  $\tau_p$  dependence verified
  - use of  $N_D^{-2}$  dependence inadequate for wide doping range
  - data suggests better fit lifetime dependence of approximately  $N_D^{-1.7}$

### Diffusion Length and Mobility Measurement

- lateral transistor test structure used to measure  $L_n, L_p$
- measurement of lifetimes allows extraction of  $\mu_n, \mu_p$
- extraction of  $\mu_n, \mu_p$  in  $10^{19}$  range shows that minority carrier mobilities exceed majority carrier mobilities